



Metrics NA TC Chapter Meeting Summary and Minutes

SEMICON West

Wednesday, July 12, 2023

3:30–5:30 PM (Pacific Time)

TC Chapter Announcements

Next TC Chapter Meeting

Thursday, November 9, 2023

1:30–5:30 PM (Pacific Time)

Table 1 Meeting Attendees

Italics indicate virtual participants

Cochairs: David Bouldin (Fab Consulting), Mark Frankfurth (Cymer), Vladimir Kraz (BestESD)

SEMI Staff: Michelle Sun

<i>Company</i>	<i>Last</i>	<i>First</i>	<i>Company</i>	<i>Last</i>	<i>First</i>
ASML Netherlands BV	Frankfurth	Mark	KLA Corporation	<i>Ganev</i>	<i>Todor</i>
Bird Technologies	Azim	Nik	SEMI	Sun	Michelle
Bird Technologies	Dummermuth	Martin	Suny Poly	<i>Eisenbraun</i>	<i>Eric</i>
Bird Technologies	Winter	John	Tokyo Electron Ltd.	Mashiro	Supika
Fab Consulting	<i>Bouldin</i>	<i>David</i>	Zama Consulting	<i>Sakamoto</i>	<i>Mitsune</i>
Intel Corporation	<i>Schneider</i>	<i>Paul</i>	SCREEN	Nishimura	Takayuki

Table 2 Leadership Changes

<i>WG/TF/SC/TC Name</i>	<i>Previous Leader</i>	<i>New Leader</i>
None		

Table 3 Committee Structure Changes

<i>Previous WG/TF/SC Name</i>	<i>New WG/TF/SC Name or Status Change</i>
License Server Certification Task Force <i>[disbanded]</i>	None

Table 4 Ballot Results

<i>Document #</i>	<i>Document Title</i>	<i>Committee Action</i>
6838	Reapproval of SEMI E114-0302E (Reapproved 0616), Test Method for RF Cable Assemblies Used in Semiconductor Processing Equipment RF Power Delivery Systems	Passed
6839	Reapproval of SEMI E115-0302E (Reapproved 0816), Test Method for Determining the Load Impedance and Efficiency of Matching Networks Used in Semiconductor Processing Equipment RF Power Delivery Systems	Passed
7056	Reapproval of SEMI E168-0915, Specification for Product Time Measurement	Passed



Table 4 Ballot Results

<i>Document #</i>	<i>Document Title</i>	<i>Committee Action</i>
7057	Reapproval of SEMI E168.1-1114, Specification for Product Time Measurement in GEM 300 Production Equipment	Passed
7058	Reapproval of SEMI E168.2-0915, Specification for Product Time Measurement for Material Control Systems	Passed
7059	Reapproval of SEMI E168.3-0915, Specification for Product Time Measurement for Transport	Passed

#1 **Passed** ballots and line items will be submitted to the ISC Audit & Review Subcommittee for procedural review.

#2 **Failed** ballots and line items were returned to the originating task forces for re-work and re-balloting or abandoning.

Table 5 Ratification Ballot Results

<i>Document #</i>	<i>Document Title</i>	<i>ISC A&R Action</i>
None		

Table 6 Activities Approved by the GCS between meetings of the TC Chapter

<i>#</i>	<i>Type</i>	<i>SC/TF/WG</i>	<i>Details</i>
None			

Table 7 Authorized Activities

Listing of all revised or new SNARF(s) approved by the Originating TC Chapter.

<i>#</i>	<i>Type</i>	<i>SC/TF/WG</i>	<i>Details</i>
7129	SNARF	CCC TF	New Standard: Test Method for Measuring Particles and Contamination by A Liquid Particle Counter of Critical Chamber Components Used in Semiconductor Wafer Processing and Inspection
7130	SNARF	CCC TF	New Standard: Test Method for Measuring Surface Contamination by Particle Concentration Through Replacement Substrate and Optical Metrology of Critical Chamber Components Used in Semiconductor Wafer Processing and Inspection

#1 SNARFs and TFOFs are available for review on the SEMI Web site at:

<http://downloads.semi.org/web/wstdsbal.nsf/TFOFSNARF>

Table 8 Authorized Ballots

<i>#</i>	<i>When</i>	<i>TF</i>	<i>Details</i>
6931	Cycle 7-2023	CCC TF	New Standard: Test Method for Measuring Organics Contamination Through Thermal Desorption or Solvent Extraction Gas Chromatography Mass Spectrometry of Critical Chamber Components Used in Semiconductor Wafer Processing and Inspection
7129	Cycle 7-2023	CCC TF	New Standard: Test Method for Measuring Particles and Contamination by A Liquid Particle Counter of Critical Chamber Components Used in Semiconductor Wafer Processing and Inspection
7130	Cycle 7-2023	CCC TF	New Standard: Test Method for Measuring Surface Contamination by Particle Concentration Through Replacement Substrate and Optical Metrology of Critical Chamber Components Used in Semiconductor Wafer Processing and Inspection
7131	Cycle 7-2023	RF Measurements	Reapproval of SEMI E135-0918, Test Method for RF Generators to Determine Transient Response for RF Power Delivery Systems Used in Semiconductor Processing Equipment



Table 8 Authorized Ballots

#	When	TF	Details
7132	Cycle 7-2023	RF Measurements	Reapproval of SEMI E143-0306 (Reapproved 0518), Test Method for Measuring Power and Variation into a 50-Ω Load and Power Variation and Spectrum into a Load with a VSWR of 2.0 at any phase Angle

Table 9 SNARF(s) Granted a One-Year Extension

#	TF	Title	Expiration Date
None			

Table 10 SNARF(s) Abolished

#	TF	Title
None		

Table 11 Standard(s) to receive Inactive Status

Standard Designation	Title
SEMI E163-0212	Guide for the Handling of Reticles and Other Extremely Electrostatic Sensitive (EES) Items Within Specially Designated Areas

Table 12 New Action Items

Item #	Assigned to	Details
1	Michelle Sun (SEMI)	Follow up on IEC meeting result

Table 13 Previous Meeting Action Items

Item #	Assigned to	Details
1	Michelle Sun (SEMI)	Follow up on IEC liaison - OPEN
2	David Bouldin (Fab Consulting)	Reach out to Chuck about ESD/ESC leadership - CLOSED
3	Supika Mashiro (TEL)	Decide on 5-year review documents for RF Measurements - CLOSED

1 Welcome, Reminders, and Introductions

David Bouldin (Fab Consulting) called the meeting to order at 3:35. The meeting reminders on antitrust issues, intellectual property issues and holding meetings with international attendance were reviewed. Attendees introduced themselves.

Attachment: Required Meeting Elements Nov 2022

2 Review of Previous Meeting Minutes

The TC Chapter reviewed the minutes of the previous meeting.



Motion: Approve the minutes as written
By / 2nd: By: Paul Schneider / Intel Corporation
Second: Eric Eisenbraun / suny poly
Discussion: None
Vote: 8-Y 0-N. Motion passed.
Attachment: Metrics-Minutes-Mar2023 v2

3 Liaison Reports

3.1 Metrics Japan TC Chapter

Michelle Sun (SEMI) reported for the Metrics Japan TC Chapter. Of note:

Last meeting

- December 14, 2022, at SEMICON Japan 2023
- Tokyo Big Sight, Room 703, 7F, Conference Tower, Tokyo, Japan / OVTCCM (Hybrid)

Next meeting

- July 26, 2023
- SEMI Japan office, Tokyo / OVTCCM (Hybrid)

Japan RF Measurement Liaison TF

- Will submit the ballot to be reviewed in SEMICON Japan December 2023.

Attachment: 20230410_MetricsJapan_Liaison_draft_v2.2

3.2 SEMI Staff Report

Michelle Sun (SEMI) gave the SEMI Staff Report. Of note:

2023 Calendar of Events

- SEMICON West
 - o July 11-13
 - o San Francisco, CA
- SEMICON Taiwan
 - o Sept 6-8
 - o Taipei, Taiwan
- SEMICON Europa
 - o Nov 14-17
 - o Munich, Germany
- SEMICON Japan
 - o Dec 13-15
 - o Tokyo, Japan

Upcoming NA Meetings

- NA Standards Fall Meetings
 - o Nov 6-9, 2023
 - o SEMI HQ, Milpitas, CA
- NA Standards Spring Meetings
 - o April 1-4, 2024
 - o SEMI HQ, Milpitas, CA
- SEMICON West
 - o July 2024
 - o Moscone Center, San Francisco

Critical Dates



2023	Ballot Submission Deadline	Voting Opens	Voting Closes
Cycle 6	July 26	August 9	September 8
Cycle 7	August 30	September 13	October 13
Cycle 8	October 4	October 18	November 17
Cycle 9	November 15	November 29	December 29

New Publications Staff

- Vivian Hoang – Sr. Specialist, Standards Publications
 - o Joined SEMI May 17, 2023.
 - o Will focus on processing ballots to reduce backlog and improve publishing time.

SEMI Standards Publications

- Total SEMI Standards in portfolio: 1,079
- Includes 327 Inactive Standards

Cycle	New	Revised	Reapproved	Withdrawn
March 2023	2	2	0	0
April 2023	1	10	4	0
May 2023	0	4	2	0
June 2023	1	10	7	0

New Standards

Cycle	Designation	Title	Committee	Region
March 2023	SEMI FH1	Test Method of Line Impedance for Electronic Textiles	Flexible Hybrid Electronics	TW
March 2023	SEMI FH2	Test Method of Sheet Resistance for Woven Electronic Textiles	Flexible Hybrid Electronics	TW
April 2023	SEMI M92	Specification for 4H-SiC Homoepitaxial Wafer	Compound Semiconductor Materials	CH
June 2023	SEMI PV100	Test Method of Wind Uplift Resistance for Photovoltaic Modules Roof (BIPV)	Photovoltaic	CH

SDO Liaisons

- ESDA
 - o MOU with ESDA signed by both parties (Paul Trio and Lisa Pimpinella)
 - o Liaison is complete.
- IEC
 - o Liaison application for IEC TC 77/WG 13 submitted to IEC.
 - o To be reviewed at their next meeting on Oct 19, 2023

Attachment: Staff Report July 2023 v3



4 Ballot Review

NOTE 1: TC Chapter adjudication on ballots reviewed is detailed in the Audits & Review (A&R) Subcommittee Forms for procedural review. The A&R forms are available as attachments to these minutes. The attachment number for each balloted document is provided under each ballot review section below.

4.1 Document #6838, Reapproval of SEMI E114-0302E (Reapproved 0616), Test Method for RF Cable Assemblies Used in Semiconductor Processing Equipment RF Power Delivery Systems

Motion: This is not a Safety Document, when all safety-related information is removed, the Document is still technically sound and complete. (Regulations ¶ 8.7.1)

By / 2nd: By: Mark Frankfurth / ASML Netherlands BV
Second: Supika Mashiro / Tokyo Electron Ltd.

Discussion: None.

Vote: 7-Y 0-N. Motion passed.

Motion: This Document passed TC Chapter review as balloted and will be forwarded to the ISC A&R SC for procedural review

By / 2nd: By: Mark Frankfurth / ASML Netherlands BV
Second: Todor Ganev / KLA Corporation

Discussion: None.

Vote: 4-Y 0-N. Motion passed.

Attachment: AR - 6838

4.2 Document #6839, Reapproval of SEMI E115-0302E (Reapproved 0816), Test Method for Determining the Load Impedance and Efficiency of Matching Networks Used in Semiconductor Processing Equipment RF Power Delivery Systems

Motion: This is not a Safety Document, when all safety-related information is removed, the Document is still technically sound and complete. (Regulations ¶ 8.7.1)

By / 2nd: By: Supika Mashiro / Tokyo Electron Ltd.
Second: Todor Ganev / KLA Corporation

Discussion: None.

Vote: 8-Y 0-N. Motion passed.

Motion: This Document passed TC Chapter review as balloted and will be forwarded to the ISC A&R SC for procedural review.

By / 2nd: By: Martin Dummermuth / BIRD ELECTRONIC CORP
Second: John Winter / Bird Technologies

Discussion: None.

Vote: 8-Y 0-N. Motion passed.

Attachment: AR – 6839

4.3 Document #7056, Reapproval of SEMI E168-0915, Specification for Product Time Measurement

Motion: This is not a Safety Document, when all safety-related information is removed, the Document is still technically sound and complete. (Regulations ¶ 8.7.1)



By / 2nd: By: Mark Frankfurth / ASML Netherlands BV
Second: Supika Mashiro / Tokyo Electron Ltd.

Discussion: None.

Vote: 6-Y 0-N. Motion passed.

Motion: This Document passed TC Chapter review as balloted and will be forwarded to the ISC A&R SC for procedural review.

By / 2nd: By: Eric Eisenbraun / suny poly
Second: Mark Frankfurth / ASML Netherlands BV

Discussion: None.

Vote: 5-Y 0-N. Motion passed.

Attachment: AR - 7056

4.4 Document #7057, Reapproval of SEMI E168.1-1114, Specification for Product Time Measurement in GEM 300 Production Equipment

Motion: This is not a Safety Document, when all safety-related information is removed, the Document is still technically sound and complete. (Regulations ¶ 8.7.1)

By / 2nd: By: Mark Frankfurth / ASML Netherlands BV
Second: Supika Mashiro / Tokyo Electron Ltd.

Discussion: None.

Vote: 5-Y 0-N. Motion passed.

Motion: This Document passed TC Chapter review as balloted and will be forwarded to the ISC A&R SC for procedural review.

By / 2nd: By: Mark Frankfurth / ASML Netherlands BV
Second: Eric Eisenbraun / suny poly

Discussion: None.

Vote: 6-Y 0-N. Motion passed.

Attachment: AR - 7057



4.5 Document #7058, Reapproval of SEMI E168.2-0915, Specification for Product Time Measurement for Material Control Systems

Motion: This is not a Safety Document, when all safety-related information is removed, the Document is still technically sound and complete. (Regulations ¶ 8.7.1)
By / 2nd: By: Mark Frankfurth / ASML Netherlands BV
Second: Supika Mashiro / Tokyo Electron Ltd.
Discussion: None.
Vote: 6-Y 0-N. Motion passed.

Motion: This Document passed TC Chapter review as balloted and will be forwarded to the ISC A&R SC for procedural review.
By / 2nd: By: Paul Schneider / Intel Corporation
Second: Mark Frankfurth / ASML Netherlands BV
Discussion: None.
Vote: 6-Y 0-N. Motion passed.

Attachment: AR - 7058

4.6 Document #7059, Reapproval of SEMI E168.3-0915, Specification for Product Time Measurement for Transport

Motion: This is not a Safety Document, when all safety-related information is removed, the Document is still technically sound and complete. (Regulations ¶ 8.7.1)
By / 2nd: By: Mark Frankfurth / ASML Netherlands BV
Second: Todor Ganev / KLA Corporation
Discussion: None.
Vote: 6-Y 0-N. Motion passed.

Motion: This Document passed TC Chapter review as balloted and will be forwarded to the ISC A&R SC for procedural review.
By / 2nd: By: Eric Eisenbraun / suny poly
Second: Mark Frankfurth / ASML Netherlands BV
Discussion: None.
Vote: 6-Y 0-N. Motion passed.

Attachment: AR - 7059

5 Subcommittee and Task Force Reports

5.1 EMC Task Force

David Bouldin (Fab Consulting) reported for the EMC Task Force. Of note:

- EMC:
 - o IEEE EMC Symposium, July 31-August 4, 2023, Grand Rapids, MI
 - o EMC Europe, September 4-8, Krakow, Poland
- ESD/EOS



- EOS/ESD Symposium and Standards, October 1-6, Riverside, CA
- Intel Proposal:
 - 9.2.1 EMC testing should be performed with the semiconductor manufacturing equipment fully installed and operational if doing so is practical and reasonable. 9.2.1 EMC (ELF emissions) testing should be performed at the manufacturer's facility with the semiconductor manufacturing equipment fully installed and operational prior to user delivery. **Vendor accountability to perform testing prior to user installation

Attachment: SEMI Stds EMC TF July 2023

5.2 RF Measurements

Supika Mashiro (TEL) reported for the RF Measurements Task Force. Of note:

- Reviewed SEMI E114 and E115 Reapproval Ballot results.
- TF recommended to reapprove SEMI E135.

5.3 Equipment RAMP

Paul Schneider (Intel) reported for the Equipment RAMP Task Force. Of note:

- Task force updating and now recording E10 and E79 webinars with new content from the last updates to the standards. Plan to re-record and publish the new versions within the next 2 quarters.
- Capturing potential future updates to E10 as the task force works through the webinars.

Attachment: SEMI NA-Metrics TC-Eqp RAMp TF Report-2023_7_12

6 Next Meeting and Adjournment

The next meeting is scheduled for November 9, 2023, at Milpitas, CA/USA. See <http://www.semi.org/standards-events> for the current list of events.

Adjournment: 5:00.

Respectfully submitted by:

Michelle Sun
 Coordinator
 SEMI North America
 Phone: 408.943.7982
 Email: msun@semi.org

Minutes tentatively approved by:

David Bouldin (Fab Consulting), Co-chair	10/2/2023
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Table 14 Index of Available Attachments#1

<i>Title</i>	<i>Title</i>
Required Meeting Elements Nov 2022	AR - 7056
Metrics-Minutes-Mar2023 v2	AR - 7057
Staff Report July 2023 v4	AR – 7058
AR - 6838	AR - 7059
AR – 6839	SEMI Stds EMC TF July 2023
SEMI NA-Metrics TC-Eqp RAMP TF Report-2023_7_12	

#1 Due to file size and delivery issues, attachments must be downloaded separately. A .zip file containing all attachments for these minutes is available at www.semi.org. For additional information or to obtain individual attachments, please contact [SEMI Staff Name] at the contact information above.